

<b>Notice of References Cited</b>	Application/Control No. 10/691,540	Applicant(s)/Patent Under Reexamination MOTOKI ET AL.	
	Examiner Matthew J. Song	Art Unit 1722	Page 1 of 1

**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-			
	B	US-			
	C	US-			
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**FOREIGN PATENT DOCUMENTS**

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**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Nam et al. "Growth of GaN and Al <sub>0.2</sub> Ga <sub>0.8</sub> N on Patterned Substrates via Organometallic Vapor Phase Epitaxy" Jpn. j. Appl. Phys. Vol 36 (May 1, 1997), Pt. 2, No. 5A, pg L532-L535.
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